

Title (en)
COATING LIQUID FOR FORMING SILICA-BASED FILM HAVING LOW DIELECTRIC CONSTANT AND SUBSTRATE HAVING FILM OF LOW DIELECTRIC CONSTANT COATED THEREON

Title (de)
BESCHICHTUNGSFLÜSSIGKEIT FÜR FILME AUF SILIKA-BASIS MIT NIEDRIGER DIELEKTRIZITÄTSKONSTANTE UND MIT DIESEM FILM BESCHICHTETES SUBSTRAT

Title (fr)
LIQUIDE DE REVETEMENT UTILISE POUR FORMER UN FILM A BASE DE SILICE PRESENTANT UNE FAIBLE CONSTANCE DIELECTRIQUE ET SUBSTRAT SUR LEQUEL EST COUCHE UN FILM A FAIBLE CONSTANCE DIELECTRIQUE

Publication
EP 0992556 A4 20050427 (EN)

Application
EP 99913676 A 19990415

Priority

- JP 9902017 W 19990415
- JP 11508298 A 19980424
- JP 13972398 A 19980521

Abstract (en)
[origin: EP0992556A1] The coating liquid for forming a silica-containing film with a low dielectric constant according to the present invention comprises: (i) fine particles of silica having a phenyl group thereon, and (ii) a polysiloxazane obtained by reacting a hydrolyzate or hydrolyzates of an alkoxy silane represented by the formula $X_nSi(OR_{<1>})_{4-n}$ and/or a halogenated silane represented by the formula $X_nSiX'_{4-n}$ with a polysilazane represented by the formula: $<CHEM>$ Further, the coating liquid for forming a silica-containing film with a low dielectric constant according to the present invention comprises: (i) fine particles of silica having a phenyl group thereon, and (ii) an oxidatively decomposable resin, the weight ratio of the fine particles of silica having a phenyl group to the oxidatively decomposable resin being in the range of 0.5 to 5. By virtue of the present invention, there can be formed a stable silica-containing film, which has a dielectric constant as low as 3 or less, which is excellent in microphotolithography workability, adherence to a substrate surface, chemical resistance such as alkali resistance and crack resistance, and which exhibits excellent planarizing performance.

IPC 1-7
C09D 183/14; C09D 201/00; C09D 5/24; C08G 77/452; C09D 183/10; H01L 21/312

IPC 8 full level
C09D 7/62 (2018.01); **C09D 183/14** (2006.01); **G03F 7/09** (2006.01)

CPC (source: EP KR US)
B05D 3/06 (2013.01 - KR); **C09D 7/62** (2017.12 - EP US); **C09D 7/67** (2017.12 - EP US); **C09D 183/04** (2013.01 - KR); **C09D 183/14** (2013.01 - EP US); **G03F 7/093** (2013.01 - EP US); **C08K 3/34** (2013.01 - EP US); **C08K 9/04** (2013.01 - EP US); **Y10T 428/249969** (2015.04 - EP US); **Y10T 428/24999** (2015.04 - EP US); **Y10T 428/2962** (2015.01 - EP US); **Y10T 428/31507** (2015.04 - EP US); **Y10T 428/31663** (2015.04 - EP US)

Citation (search report)

- [A] US 5256487 A 19931026 - MYERS RONALD E [US]
- [A] US 4560711 A 19851224 - SUZUKI TOSHIO [JP]
- [AP] US 5883219 A 19990316 - CARTER KENNETH RAYMOND [US], et al
- See references of WO 9955789A1

Cited by
CN107868610A; US6562465B1; KR100382702B1; EP1420947A4; CN103950940A; CN110452614A; KR100451044B1

Designated contracting state (EPC)
DE GB NL

DOCDB simple family (publication)
EP 0992556 A1 20000412; **EP 0992556 A4 20050427**; **EP 0992556 B1 20120509**; EP 1790703 A2 20070530; EP 1790703 A3 20090812; EP 1790703 A8 20100630; EP 1790703 B1 20140730; KR 100600630 B1 20060713; KR 100600631 B1 20060713; KR 20010014143 A 20010226; KR 20060066137 A 20060615; TW I221159 B 20040921; US 6562465 B1 20030513; WO 9955789 A1 19991104

DOCDB simple family (application)
EP 99913676 A 19990415; EP 07002273 A 19990415; JP 9902017 W 19990415; KR 19997012205 A 19991223; KR 20067009944 A 20060522; TW 88106468 A 19990423; US 44668699 A 19991223